## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the Application of:	CERTIFICATE OF EXPRESS MAILING
Gao, Xinhao, et al.	In accordance with 37 C.F.R. § 1.10, I
Serial No.: Not yet assigned	hereby certify that this paper (and all papers referred to herein) is being deposited on April 02, 2004 with the United States Postal Service in an envelope addressed to: Mail
Filed: April 2, 2004	Stop Patent Application, Commissioner for Patents, P.O. Box 1450, Alexandria, VA
For: "UV/EB Cured Integrated Magnets – Composition and Method of Fabrication"	22313-1450 utilizing the "Express Mail Post Office to Addressee" service of the United States Postal Service under Mailing Label No. EV 303832329 US
Prior Group Art Unit: 1775	Cardo Borngein
Prior Examiner: Kevin Burnett	Donald J. Pochopien Registration No. 32,167 Attorney for Applicants

## INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR § 1.97 AND § 1.98

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Applicants wish to call to the attention of the Examiner, patents and documents, as listed on PTO Form 1449, which may be considered material to the examination of the above-identified patent application. Two copies of PTO Form 1449, itemizing the disclosures is also enclosed. It is respectfully requested that the cited information be expressly considered during the prosecution of this application, and the references be made of record therein and appear among the "references cited" on any patent to issue therefrom. No copies of the cited references are enclosed as they were provided in the parent application USSN 10/184,867.

Because this Information Disclosure Statement is being filed before the mailing date of a First Office Action on the merits, no fee is due.

However, if any fees are due, the Assistant Commissioner is authorized

to charge any fees for the filing of this paper to the Deposit Account No. 13-0017 in the name of McAndrews, Held & Malloy, Ltd. A duplicate copy of this document is being cofiled herewith.

Respectfully submitted,

MCANDREWS, HELD & MALLOY, LTD.

By

Donald J. Pochopien Registration No. 32,167 Attorney of Record 34th Floor 500 West Madison Chicago, Illinois 60661 (312) 775-8133

Dated: April 2, 2004

Form PTO-1449 (Rev. 8-83)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 1904 / 13747US02	SERIAL NO. Not yet assigned		
(modified)  INFORM	IATION DISCLOSURE CITATION	APPLICANT(s): Gao, Xinhao, et al.			
	(Use several sheets if necessary)	FILING DATE April 2, 2004	GROUP ART UNIT: 1775		

U.S. PATENT DOCUMENTS								
EXAMINER INITIAL		DOCUMENT NO.	DATE			SUBCLASS	FILING DATE IF APPROPRIATE	
	A1	5,458,282	10/17/95	Martin, J. J.				
	A2	5,641,116	06/24/97	Martin, J. J.				
	A3	5,676,307	11/14/97	Martin, J. J.				
	A4	5,682,670	11/04/97	Bell, J.F., et al.	<u> </u>			
	A5	5,869,148	02/09/99	Silverschotz, S.B., et al.				
	A6	5,868,498	02/09/99	Martin, J. J.				
	A7	5,924,624	07/20/99	Martin, J. J.			-	
	A8	6,024,278	02/15/00	Martin, J. J.			-	
	A9	6,024,277	02/15/00	Martin, J. J.				
	A10	6,136,398	10/24/00	Willett, P. S., et al.				
***************************************	A11	6,237,837	05/29/01	Martin, J. J.			11 MM 12 A AV	
12.12	A12	6,342,273	01/29/02	Handels, J. W.H., et al.	<b>†</b>			
	A13	5,501,903	03/26/96	Erkkila et al.				
	A14	6,863,847	01/1999	De Voe et al.				
	A15	6,143,193	11/2000	Akioka et al.				

FOREIGN PATENT DOCUMENTS								
EXAMINER INITIAL		DOCUMENT NO.	PUBLICATION	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
INITIAL		,	DATE				YES	NO
C1 MMPA, Permanent Magnet Guidelines, Supplement to MMPA Standard No. 0100, MMPA PMG-88, Magnetic Materials Producers Association, 1987, pp. 1-27.								
	C2 MMPA, Standard Specifications for Permanent Magnet Materials, MMPA Standard 0100, Magnetic Materials Producers Association, 1964, pp. 1-28.							<b>I</b> agnetic

EXAMINER DATE	E CONSIDERED:

<sup>\*</sup>EXAMINER: Initial citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.